

Abstract Submitted
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Are the surfaces of CrO₂ half-metallic? C.A. VENTRICE, JR., Texas State Univ., D.R. BORST, Univ. of New Orleans, H. GEISLER, Texas State Univ., J. VAN EK, Seagate Technologies, Y.B. LOSOVYJ, Louisiana State Univ., P.S. ROBBERT, Univ. of New Orleans, U. DIEBOLD, Tulane Univ., J.A. RODRIGUEZ, Brookhaven National Lab, G.X. MIAO, A. GUPTA, Univ. of Alabama — Previous photoelectron spectroscopy studies of CrO₂ have found either no density of states or a very low density of states at the Fermi level, suggesting that CrO₂ is a semiconductor or a semimetal. This is in contradiction to calculations that predict that CrO₂ should be a half-metallic ferromagnet. Recently, techniques have been developed to grow high-quality epitaxial films of CrO₂ on TiO₂ substrates by chemical vapor deposition. We present photoelectron spectroscopy measurements of epitaxial CrO₂(110)/TiO₂(110) and CrO₂(100)/TiO₂(100) grown using a CrO₃ precursor. In addition, measurements of epitaxial Cr₂O₃(0001)/Pt(111) films grown by thermal evaporation of Cr in an oxygen atmosphere are presented as a reference for reduced CrO₂ films. The measurements of the CrO₂ surfaces show no emission at the Fermi level after sputtering and annealing the surfaces in oxygen, even though our soft core photoemission data and low energy electron diffraction measurements provide evidence that stoichiometric CrO₂ is present. The consequence of this is that neither surface of CrO₂ is metallic. This behaviour could result from a metal to semiconductor transition at the (110) and (100) surfaces.

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